## WHAT IS CLAIMED IS:

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 A resin composition for encapsulating a semiconductor chip comprising:

5 an epoxy resin (A);

a phenol resin (B);

an inorganic filler (C);

a curing accelerator (D);

a silane coupling agent (E); and

Compound (F) containing two and more hydroxyl groups combined with each of adjacent carbon atoms comprising an aromatic ring.

- 2. The resin composition for encapsulating a semiconductor chip according to Claim 1, wherein the resin composition comprises said compound (F) in more than or equal to 0.01 wt%.
- 3. The resin composition for encapsulating a semiconductor chip according to Claim 1, wherein the resin composition comprises said silane coupling agent (E) in 0.01 wt% to 1 wt% both inclusive.
- 4. The resin composition for encapsulating a semiconductor

  20 chip according to Claim 1, wherein said epoxy resin (A) comprises
  an epoxy resin represented by general formula (1):

$$H_{2}C \longrightarrow CH - CH_{2} \longrightarrow R_{1} \longrightarrow R_{2} \longrightarrow CH_{2} - CH_{2}$$

wherein  $R_1$  represents a single bond or saturated or unsaturated hydrocarbon having up to three carbon atoms;  $R_2$  to  $R_9$ , which may be the same or different from each other, represent hydrogen

or saturated hydrocarbon having up to four carbon atoms; and n is a positive number more than 0 and up to 5 as an average, in 50 wt% or more.

5. The resin composition for encapsulating a semiconductor chip according to Claim 1, wherein said Compound (F) contains two hydroxyl groups combined with each of adjacent carbon atoms comprising said aromatic ring.

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- 6. The resin composition for encapsulating a semiconductor chip according to Claim 1, wherein the aromatic ring is a naphthalene ring.
- 7. The resin composition for encapsulating a semiconductor chip according to Claim 6, wherein said Compound (F) contains two hydroxyl groups combined with each of adjacent carbon atoms comprising said naphthalene ring.
- 8. The resin composition for encapsulating a semiconductor chip according to Claims 1, wherein the resin composition comprises said inorganic filler (C) in 80 wt% to 94 wt% both inclusive.
- 9. A semiconductor device wherein a semiconductor chip is encapsulated by the use of a resin composition for encapsulating a semiconductor chip according to Claims 1.